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(12) **United States Design Patent**
Rydlewicz

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(54) **DIAMOND**

(71) Applicant: **LUCKY EYE LIMITED**, Hong Kong (HK)

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(**) Term: **15 Years**

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(30) **Foreign Application Priority Data**

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(51) **LOC (12) Cl.** **11-01**

(52) **U.S. Cl.**
USPC **D11/90**

(58) **Field of Classification Search**
USPC D11/1, 2, 16, 26–29, 34, 35, 36, 89–92
CPC A44C 17/00; A44C 17/001; A44C 17/002;
A44C 17/003; A44C 17/005; A44C
17/006; A44C 17/007; A44C 17/008
See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

D522,401 S * 6/2006 Rydlewicz D11/90
D688,970 S * 9/2013 Rydlewicz D11/90

D738,254 S * 9/2015 Hakimian D11/90
D786,125 S * 5/2017 Liang D11/90
D839,770 S * 2/2019 Rydlewicz D11/90
D839,772 S * 2/2019 Rydlewicz D11/90
D839,773 S * 2/2019 Rydlewicz D11/90
D839,774 S * 2/2019 Rydlewicz D11/90
D839,775 S * 2/2019 Rydlewicz D11/90
D839,778 S * 2/2019 Rydlewicz D11/90
2013/0019636 A1 * 1/2013 Rydlewicz A44C 17/001
63/32

FOREIGN PATENT DOCUMENTS

CN RGN-305209110 * 6/2019

* cited by examiner

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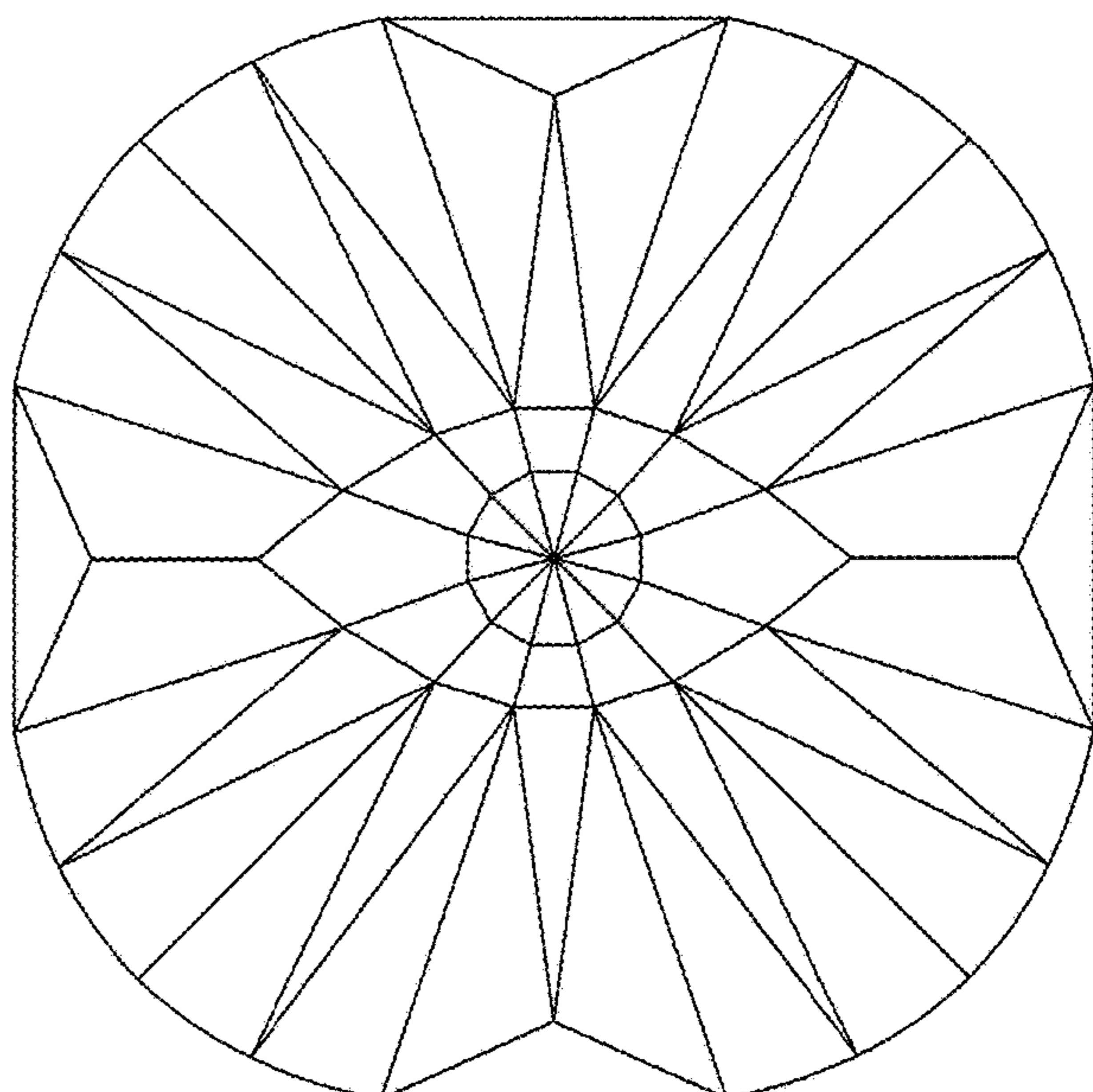
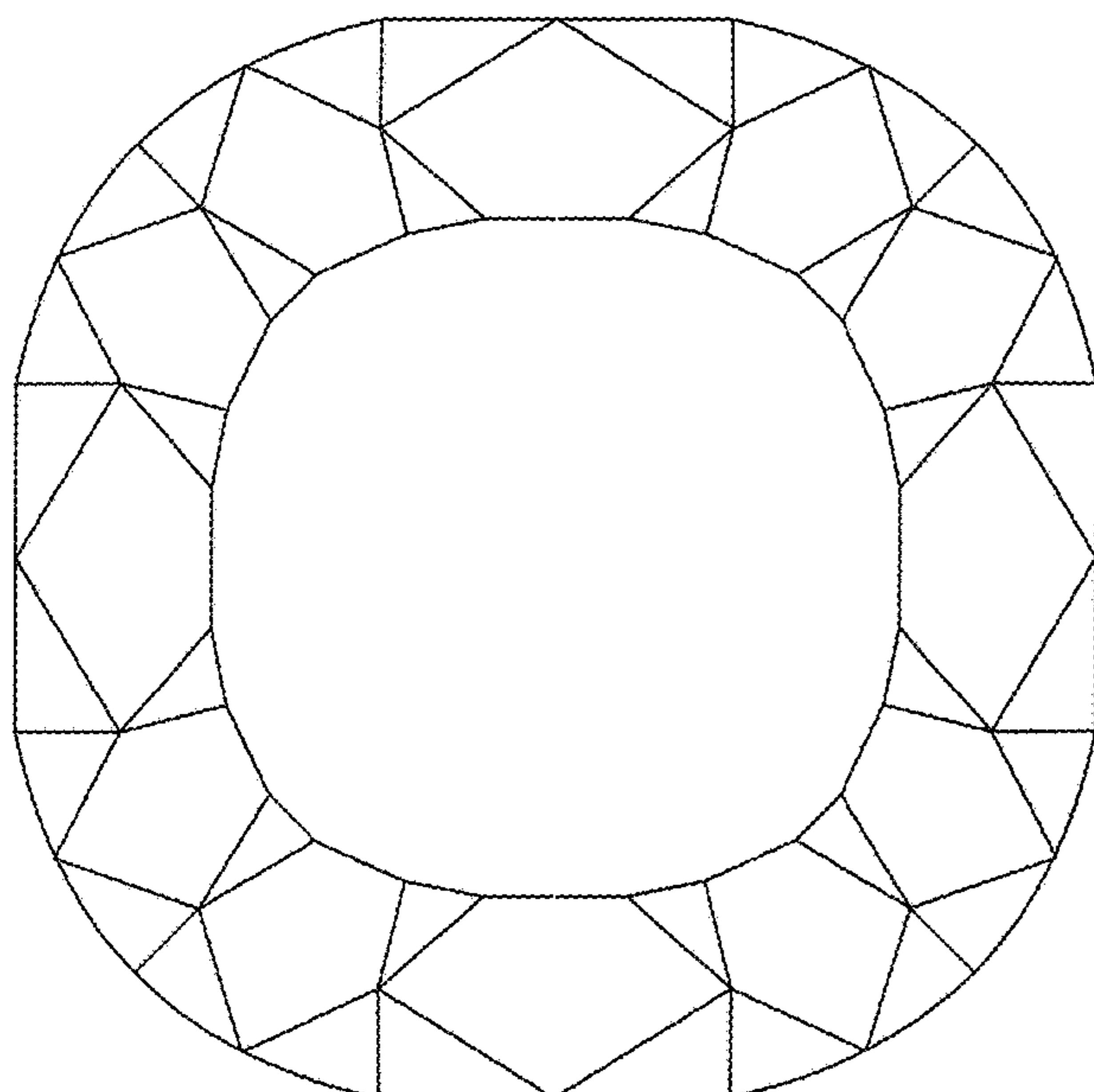
(57) **CLAIM**

The ornamental design for diamond, as shown and described.

DESCRIPTION

FIG. 1 is a top plan view of the claimed design;
FIG. 2 is a side elevational view, the opposite side view being identical;
FIG. 3 is a side elevational view, the opposite side view being identical; and,
FIG. 4 is a bottom plan view.

1 Claim, 4 Drawing Sheets



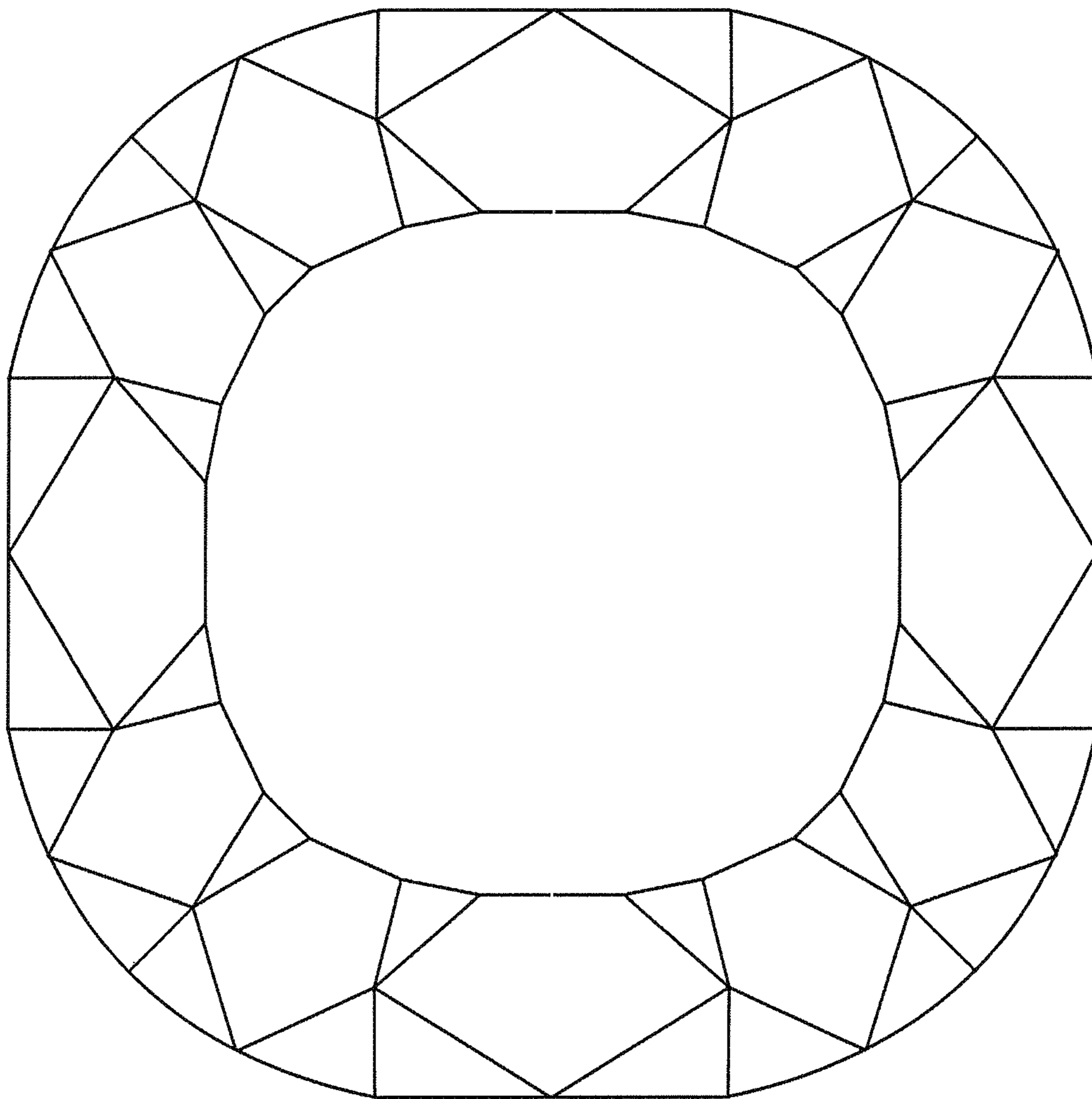


FIG. 1

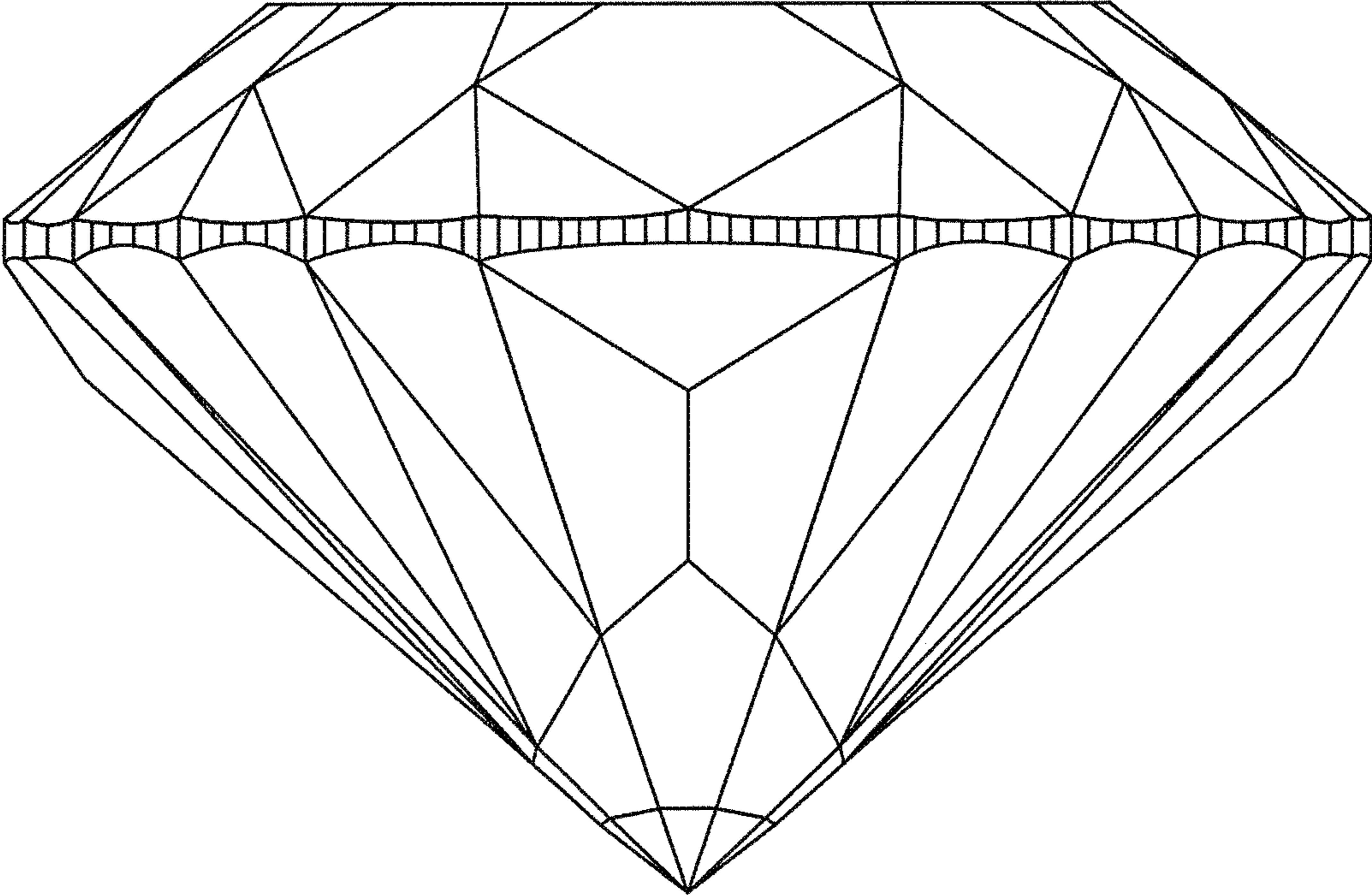


FIG. 2

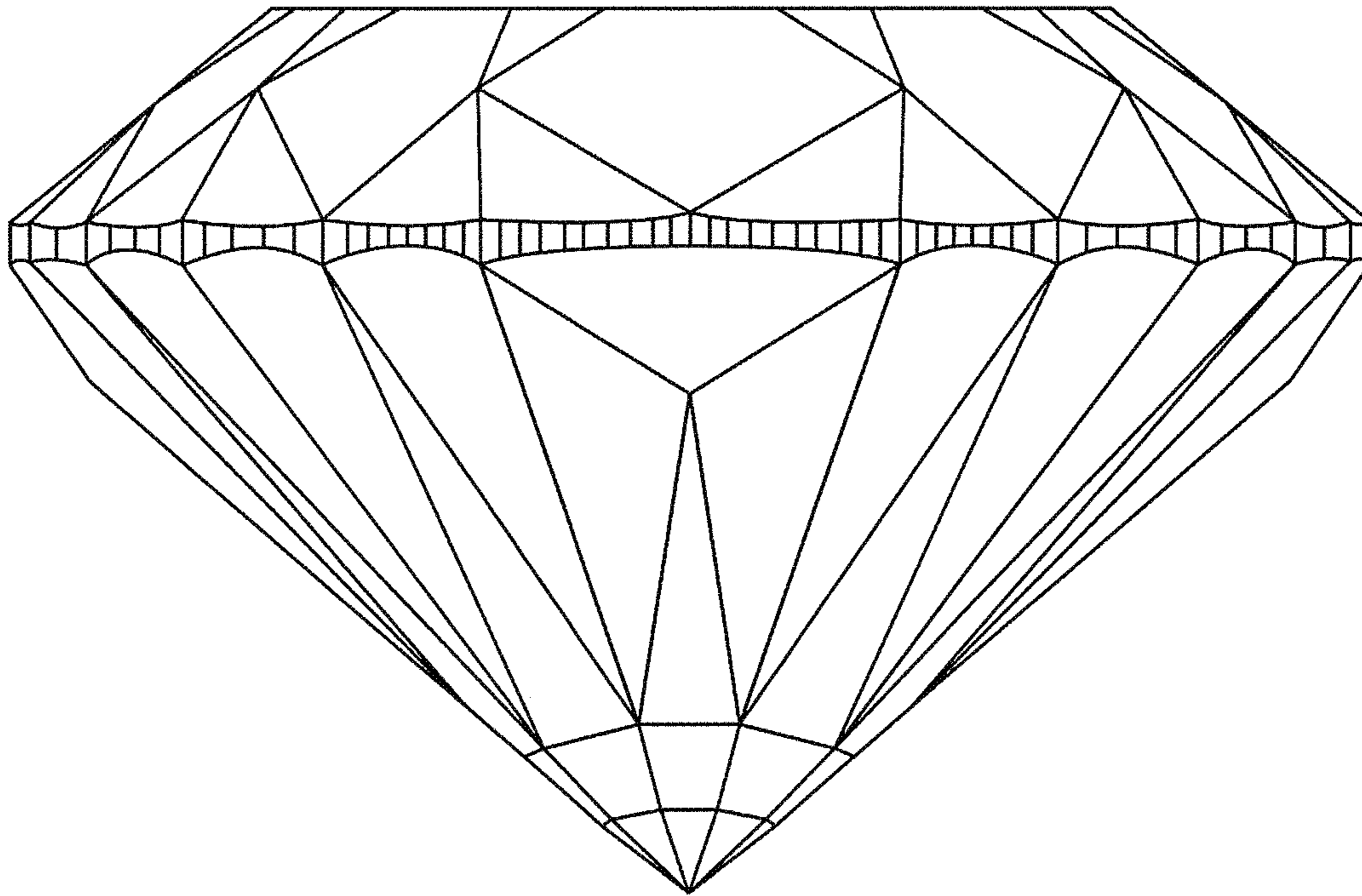


FIG. 3

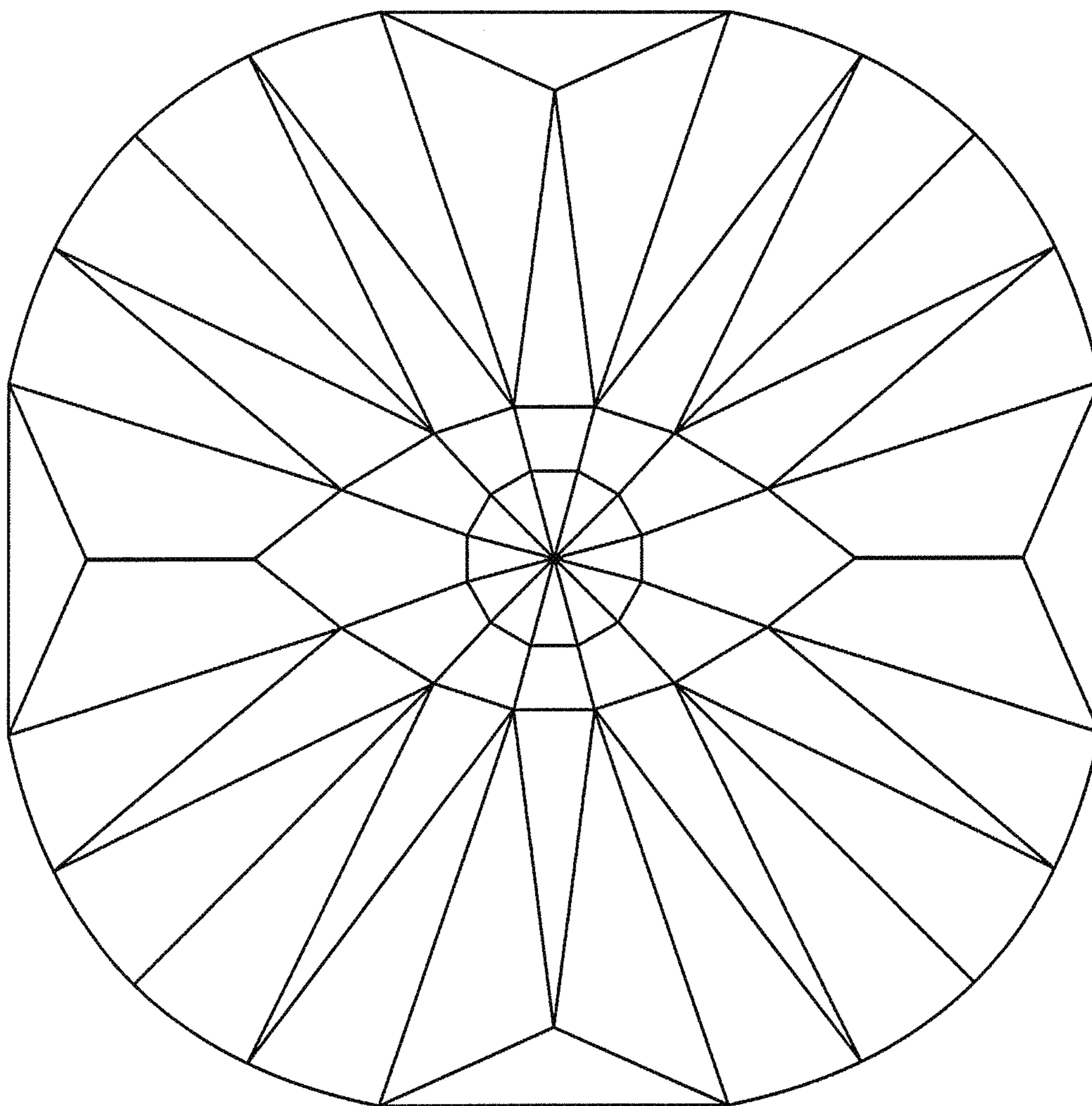


FIG. 4